

FOREWORD

The first International Symposium on Organosilicon Chemistry was held at Prague during 6–9 September 1965 under the auspices of the International Union of Pure and Applied Chemistry and was organized by the Czechoslovak Academy of Sciences and by the Czechoslovak Chemical Society. There were 334 participants from 20 countries, the largest quotas were from the U.S.S.R., German Federal Republic, United Kingdom, Czechoslovakia, the U.S.A., and France. The symposium was inaugurated by the President of the Czechoslovak Academy of Sciences, František Šorm. A total of 22 main lectures and 78 scientific communications were presented. The scientific programme of the symposium was organized in two sections and was subdivided into several topical groups.

It was stated at the conclusion of the symposium that the organization of this first International Symposium on Organosilicon Chemistry was successful both technically and with regard to the selection of symposium topics. It was therefore decided at the concluding session to organize a similar symposium at regular time intervals. An *ad hoc* coordination committee was then elected, including Prof. West (U.S.A.), Prof. Schmidt (Germany), Prof. Voronkov (U.S.S.R.), Prof. Calas (France), Prof. Eaborn (U.K.) and Prof. Bažant (Czechoslovakia).

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